

# 1/f FREQUENCY NOISE OF 2 GHz HIGH-Q OVER-MODED SAPPHIRE RESONATORS\*

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## Abstract

We present experimental results on intrinsic 1/f frequency modulation (FM) noise in high-overtone thin-film sapphire resonators that operate at 2 GHz. The resonators exhibit several high-Q resonant modes approximately 100 kHz apart, which repeat every 13 MHz. A loaded Q of approximately 20,000 was estimated from the phase response. The results show that the FM noise of the resonators varied between  $S_y(10 \text{ Hz}) = -202 \text{ dB}$  relative (rel) to 1/Hz and  $-210 \text{ dB}$  rel to 1/Hz. The equivalent phase modulation (PM) noise of an oscillator using these resonators (assuming a noiseless amplifier) would range from  $\mathcal{L}(10 \text{ Hz}) = -39$  to  $-47 \text{ dBc/Hz}$ .

## Introduction

The frequency stability of an oscillator is a function of the Q of the resonator and the intrinsic noise of its components (resonator, loop amplifier, and gain control circuitry). Important characteristics of a resonator are thus high Q and low frequency noise. If a resonator with frequency modulation (FM) noise of  $S_y(f)$  is used in an oscillator, its contribution to the phase modulation (PM) noise of the oscillator is given by [1]

$$\mathcal{L}(f) = \frac{1}{2} \left( \frac{v_o}{f} \right)^2 S_y(f) \quad (1)$$

where  $\mathcal{L}(f)$  is the noise in the oscillator,  $v_o$  is the carrier frequency, and  $f$  is the Fourier frequency.

In this paper we report on the intrinsic FM noise of 2 GHz over-moded resonators. These resonators are made of thin-film piezoelectric material deposited on a high-Q sapphire substrate. Figure 1 shows a diagram of the over-moded resonator. The piezoelectric material was aluminum nitride ( $2 \mu\text{m}$  thick). The sapphire used as substrate was 0.5 mm thick and the aluminum electrodes were  $0.2 \mu\text{m}$  thick. Since the thickness of the substrate is much larger than the thickness of the thin-film, the resonator operates at a large mode number. In this study, we used resonators arranged in a 3/2 ladder filter (three resonators in series and two in shunt) as shown in Fig. 2. More details on the resonator design, fabrication, and operation are given in [2-3]. The over-moded resonators in this study do not exhibit a turnover temperature, and their temperature coefficient is the temperature coefficient of the sapphire, approximately  $-30 \text{ ppm/}^\circ\text{C}$ . The advantages of these resonators over other technologies are their high Qs, in addition to their small size which, in principle, would make possible to build an oscillator in a very small package.

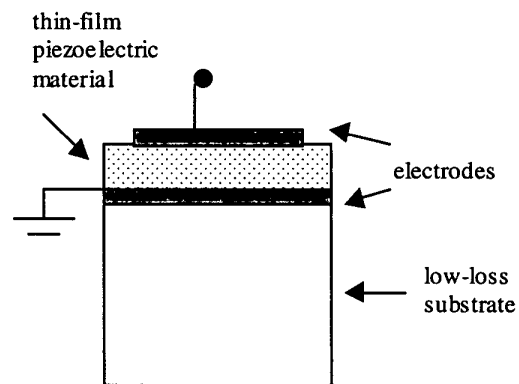
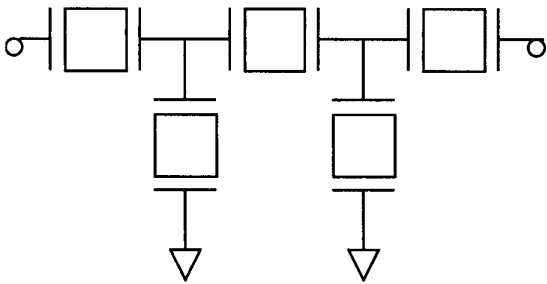


Figure 1. Diagram of over-moded resonator.



**Figure 2.** 3/2 ladder filter structure used (three resonators in series and two resonators in shunt).

### Transmission Characteristics

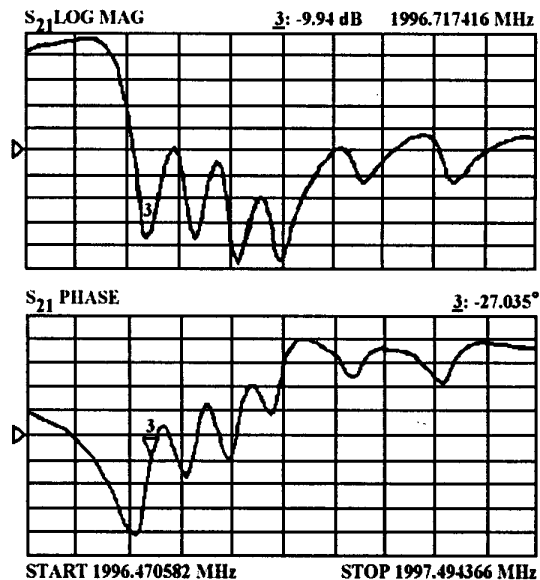
The resonators were ovenized in order to stabilize their transmission characteristics. A network analyzer was used to measure the transmission characteristics of the ovenized resonators. The transmission characteristics of the three resonators tested are shown in Figures 3-5. Resonator 1 shows four high-Q resonances approximately 100 kHz apart and Resonators 2 and 3 show two high-Q resonances approximately 100 kHz apart. These resonances are repeated approximately every 13 MHz. The insertion loss varies between 10-14 dB among the resonators and the different modes. An estimate for the loaded Q of the modes was obtained from the phase response and the relation

$$\Delta\phi = 2Q_L \Delta y \quad (2)$$

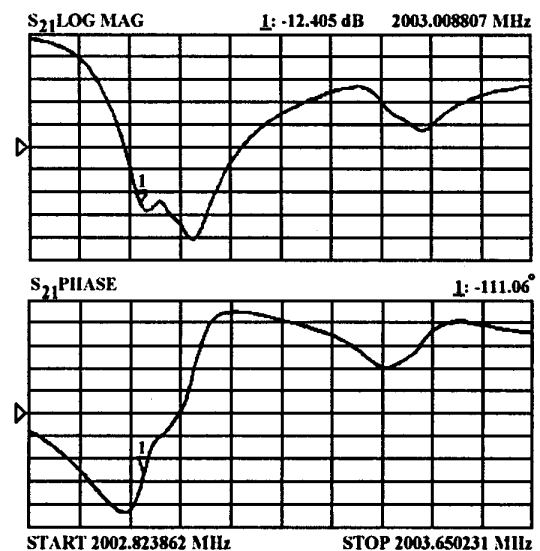
where  $\Delta\phi$  refers to the phase difference,  $Q_L$  is the loaded Q of the resonator, and  $\Delta y$  refers to the fractional frequency difference. The estimated  $Q_L$  was 20,000.

### Frequency Noise measurements

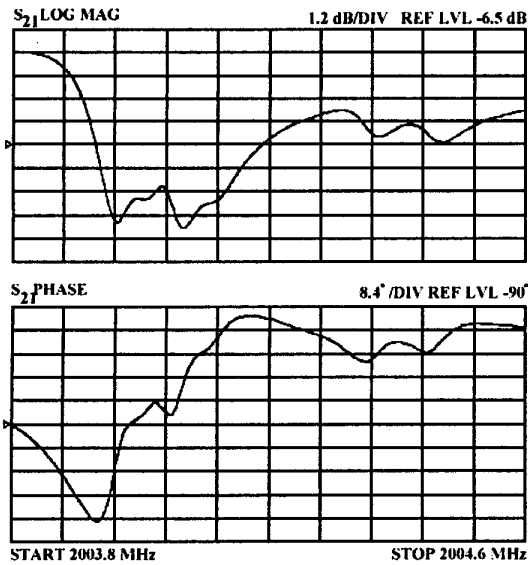
Figure 6 shows a simplified block diagram of the frequency discriminator measurement system used for measuring the intrinsic FM noise of the ovenized resonators [4]. A signal generator was used as the driving source and a single overmoded resonator was used as the frequency discriminator. As shown, carrier suppression was used to improve the noise floor of the measurement system [5,6].



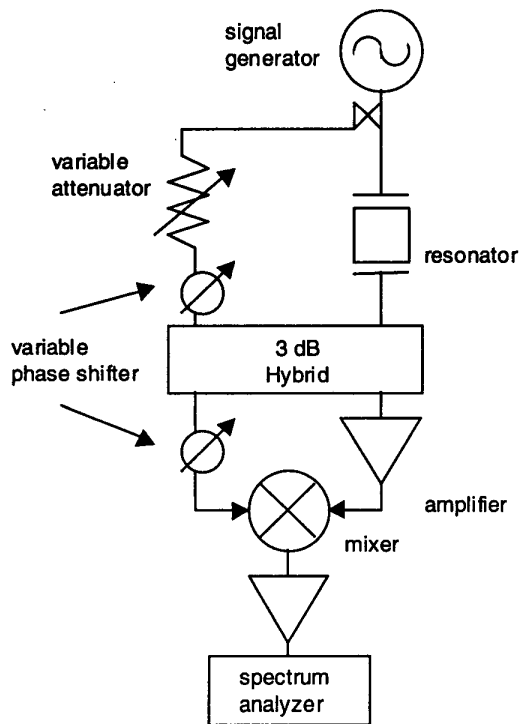
**Figure 3.** Transmission characteristics of Resonator 1. The start frequency is 1996.470582 MHz and the stop frequency is 1997.494366 MHz. For the magnitude plot the reference level is -6.5 dB and the vertical scale is 1 dB/division. For the phase plot the reference level is  $-20^\circ$  and the vertical scale is  $8.6^\circ$  per division.



**Figure 4.** Transmission characteristics of Resonator 2. The start frequency is 2002.823862 MHz and the stop frequency is 2003.650231 MHz. For the magnitude plot the reference level is -8.7 dB and the vertical scale is 1.4 dB/division. For the phase plot the reference level is  $-84.4^\circ$  and the vertical scale is  $9.7^\circ$  per division.



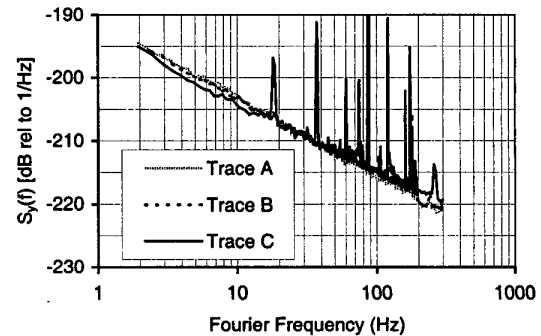
**Figure 5.** Transmission characteristics of Resonator 3. The start frequency is 2003.8 MHz and the stop frequency is 2004.6 MHz. For the magnitude plot the reference level is  $-6.5$  dB and the vertical scale is 1.2 dB/division. For the phase plot the reference level is  $-90^\circ$  and the vertical scale is  $8.4^\circ$  per division.



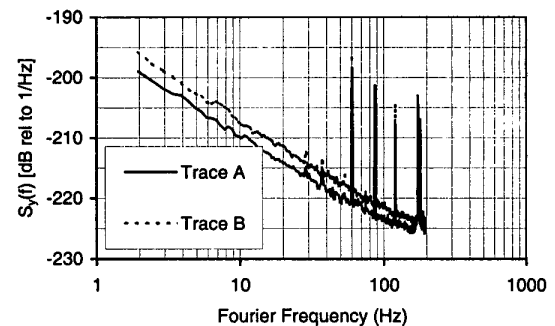
**Figure 6.** Block diagram of frequency discriminator measurement system with carrier suppression.

Figure 7 shows FM noise results for Resonator 2 at a 12 dBm drive level. In this case, measurements were made at three different modes:  $f_1 = 1.990307400$  GHz (Trace A),  $f_2 = 2.002994680$  GHz (Trace B), and  $f_3 = 2.003062060$  GHz (Trace C). The results for all three modes are very close (within 2 dB). Based on the manufacturer's PM noise specifications, the PM noise of the frequency synthesizer used in the measurement system does not contribute to the measured noise at Fourier frequencies below 1 kHz. Nevertheless, the measured FM noise at Fourier frequencies above 400 Hz was limited by synthesizer noise, probably amplitude modulation (AM) noise.

Figure 8 shows FM noise results for Resonator 3 at a 12 dBm drive level. In this case, noise measurements were made at two different modes:  $f_1 = 2.003935940$  GHz (Trace A) and  $f_2 = 2.004041860$  GHz (Trace B). As shown, the two traces are close, within 3 dB.



**Figure 7.** Intrinsic FM noise in three modes of Resonator 2.



**Figure 8.** Intrinsic FM noise in two modes of Resonator 3.

Table 1 shows a summary of the FM noise of the three resonators. The column labeled  $S_y(10\text{ Hz})$  refers to the FM noise of the resonators and the column labeled  $\mathcal{L}(10\text{ Hz})$  refers to the PM noise of an oscillator built using the resonator and a noiseless amplifier. This last column was obtained from the  $S_y(f)$  data and Equation 1. These results show that there is a spread of 8 dB in the FM noise of the resonators.

**Table 1.** Frequency noise for overmoded sapphire resonators.

Resonator	Frequency (GHz)	$S_y(10\text{ Hz})$ [dB rel to 1/Hz]	$\mathcal{L}(10\text{ Hz})$ [dBc/Hz]
1	1.996683000	-202	-39
2	1.990307400	-203	-40
2	2.002994680	-204	-41
2	2.003062060	-204	-41
3	2.003935940	-210	-47
3	2.004041860	-208	-45

## Discussion and Conclusion

The thin-film over-moded resonator transmission characteristics exhibit multiple resonances (100 kHz apart), which repeated every 13 MHz from 1 GHz to 2 GHz. These close resonances are probably due to the lack of parallelism in the surfaces of the substrate. The FM noise of the 2 GHz over-moded resonators was measured using a frequency discriminator measurement system with carrier suppression. To our knowledge, these are the first reported FM noise measurements for this high-Q resonator technology. The spread of the noise results among the three resonators was 8 dB, with the noise ranging from  $S_y(10\text{ Hz}) = -202\text{ dB rel to } 1/\text{Hz}$  to  $-210\text{ dB rel to } 1/\text{Hz}$ . The equivalent PM noise of an oscillator using such resonators (assuming a noiseless amplifier) would range from  $\mathcal{L}(10\text{ Hz}) = -39$  to  $-47\text{ dBc/Hz}$ .

The resulting PM noise is approximately 30 dB lower than the typical PM noise of commercial VCOs, approximately  $\mathcal{L}(10\text{ Hz}) = -10\text{ dBc/Hz}$ . However, over-moded resonators lack the tuning capability of the VCOs due to the proximity of the resonant modes. A possible oscillation scheme would be to phase-lock a VCO to the thin-film resonator to obtain lower close-in PM noise and tunability over a 1 GHz range (every 13 MHz). The problem with this scheme is that due to the close proximity of the multiple resonances, a very narrowband filter would be needed to select the correct resonance.

Three other acoustic technologies operate in this general frequency range. Surface transverse wave (STW) resonators have Q's of a few thousand and exhibit low noise: PM noise as low as  $\mathcal{L}(10\text{ Hz}) = -50\text{ dBc/Hz}$  has been reported for 1 GHz STW oscillators [7]. STW resonators can also be used in VCOs and they exhibit a turnover temperature [8,9]. Surface acoustic wave (SAW) resonators typically operate at frequencies from 100 MHz up to 2 GHz [10]. Phase noise reports of  $\mathcal{L}(1\text{ Hz}) = -55\text{ dBc/Hz}$  for a 500 MHz oscillator with a loaded Q of 1000 has been reported in [11]. This technology can potentially result in low noise oscillators at 2 GHz. In addition, another over-moded resonator previously studied is the high-overtone bulk-acoustic resonator (HBAR) [12]. In these two-port resonators, the high-Q substrate was located between two thin-film piezoelectric transducers. FM noise results of  $S_y(100\text{ Hz}) \cong -250\text{ dB rel to } 1/\text{Hz}$  were reported for 640 MHz HBAR resonators [12].

In principle, over-moded resonators can be used to build low-noise oscillators that are very small in size, but the circuit would require a pre-selector to select the oscillation mode. These over-moded resonators are potentially much smaller than other competing resonator technologies, nevertheless, these over-moded resonators do not have a turnover temperature and exhibit a temperature coefficient of approximately  $-30\text{ ppm}/^\circ\text{C}$ .

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